Application No. Applicant(s) GRAF ET AL. 10/788,861 Notice of Allowability Examiner Art Unit 2881 James J. Leybourne -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308. 1. This communication is responsive to <u>Amendment received September 12, 2005.</u> 2. The allowed claim(s) is/are 1-7,10,11 and 13-25. 3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). b) Some* c) None of the: a) 🗌 All 1.
☐ Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: _____.

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05)	Notice of Allowability	Part of Paper No./Mail Date 092705
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO 3. ☐ Information Disclosure Statements (PTO-1449 or PT Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for De of Biological Material	D-948) 6. ☑ Interview Summa Paper No./Mail TO/SB/08), 7. ☐ Examiner's Ame	Date
6. DEPOSIT OF and/or INFORMATION about the attached Examiner's comment regarding REQUIRE	e deposit of BIOLOGICAL MATERIA MENT FOR THE DEPOSIT OF BIOLOG	L must be submitted. Note the GICAL MATERIAL.
 CORRECTED DRAWINGS (as "replacement sheet (a) including changes required by the Notice of Dra 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Exapper No./Mail Date Identifying indicia such as the application number (see 3 each sheet. Replacement sheet(s) should be labeled as s 	aftsperson's Patent Drawing Review(Pi e aminer's Amendment / Comment or in th 7 CFR 1.84(c)) should be written on the dra	e Office action of awings in the front (not the back) of
4. A SUBSTITUTE OATH OR DECLARATION must b INFORMAL PATENT APPLICATION (PTO-152) wh		
Applicant has THREE MONTHS FROM THE "MAILING noted below. Failure to timely comply will result in ABANTHIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	NDONMENT of this application.	ply complying with the requirements

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DETAILED ACTION

According to the "Amendment" received September 12, 2005, claims 1,
 14, 19, 22 and 24 have been amended; 8, 9 and 26 have been canceled.

Response to Arguments

2. Applicant's Remarks received September 12, 2005 have been fully considered and are persuasive.

Examiner's Amendment

3. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

In claim 1 on line 12 following "density", insert – during ion implantation ---.

Authorization for this examiner's amendment was given in a telephone interview with Thomas G. Eschweiler on September 28, 2005.

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Allowable Subject Matter

4. Claims 1-7, 10-11 and 13-25 are allowed. The following is an examiner's statement of reasons for allowance:

Regarding independent claims 1 and 19, the prior art fails to disclose or make obvious an ion implantation system comprising:

- a component downstream of the ion source for modulating the ion beam current density via at least one of a generated electric and magnetic field;
 and
- a measurement component for taking readings of beam current, the modulating component adjusting the beam current density in response to readings taken by the measurement component during ion implantation.

Claims 2-7, 10-11 and 13-18 are allowed by virtue of their dependency on claim 1.

Claims 20 and 21 are allowed by virtue of their dependency on claim 19.

With respect to the independent claim 22, the prior art fails to disclose or make obvious an ion implantation system comprising:

- a first modulating component associated with the ion source for modulating the beam current density via at least one of a generated electric and magnetic field; and
 - a second modulating component downstream of the ion source for

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selectively modulating the ion beam current density via at least one of a generated electric and magnetic field.

Claims 3 and 25 are allowed by virtue of their dependency on claim 22.

The main features that separates the apparatus apart from prior art are the use of closed loop feedback for claims 1 and 19 and the use of a second beam current density for claim 22.

5. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance"

Relevant Prior Art

- 6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.
- 7. The following patents are cited to show further show the state of the art with respect to ion beam current modulation in ion implantation systems:

USPN 5834786 to White et al.

USPN 6661016 to Berrian

USPN 4234797 to Ryding.

USPN 4290012 toBerte et al.

US 20050017202 A1 to White

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to James J. Leybourne whose telephone number is (571) 272-2478. The examiner can normally be reached on M-F 9:00-6:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John R Lee can be reached on (571) 272-2477. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (tollfree).

September 29, 2005

Milesta Sells
NIKITAWELLS
PRIMARY EXAMINER 09/29/05

JJL